IN THE CLAIMS:

1. (Cancelled).

2. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said first component comprises two cationically polymerizable functional

groups.

3. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said monomer portion of said first component is an organic monomer

selected from the group of aryl, norbornane, and combinations thereof.

4. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said monomer portion of said first component is an organosilicone

monomer containing (SiR₂O) or (SiRO_{3/2}) units, wherein R is hydrogen, a methyl group, a

phenyl group, a hydrocarbon, or a fluorocarbon group.

5. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said cationically polymerizable functional group of said first component is

selected from the group of epoxy functional groups, vinyl ether functional groups, and

combinations thereof.

6. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said first component is

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$$\begin{bmatrix} CH_3 \\ Si \end{bmatrix}_2 C$$

- 7. (Currently Amended) A material composition An article as set forth in claim [[1]]36 wherein said crosslinker comprises four cationically polymerizable functional groups.
- 8. (Currently Amended) A material composition An article as set forth in claim [[1]]36 wherein said crosslinker comprises silicone.
- 9. (Currently Amended) A material composition An article as set forth in claim [[1]]36 wherein said cationically polymerizable function groups of said crosslinker are selected from the group of epoxy functional groups, vinyl ether functional groups, and combinations thereof.
- 10. (Currently Amended) A material composition An article as set forth in claim [[1]]36 wherein said crosslinker is

$$\begin{bmatrix} & & & CH_3 & \\ & & & Si & O \end{bmatrix}_4 Si$$

H&H No.: 71,038-102 Serial No.: 10/598,943 11. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein first component and/or said crosslinker are the reaction product of 4-vinyl-

1-cyclohexane-1,2-epoxide and an SiH-functional silicone compound.

12. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said cationic photoinitiator comprises an active cationic species and an

anionic species, with said cationic species comprising an onium salt.

13. (Currently Amended) A material composition An article as set forth in claim 12

wherein said onium salt is a diaryliodonium salt, a triarylsulfonium salt, or a tetraaryl

phosphonium salt and said anionic species is selected from the group of BF₄, PF₆, AsF₆,

 SbF_6 , and $(C_6F_5)_4B$.

14. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said first component is present from 90-98 parts by weight, said crosslinker

is present from 1-9 parts by weight, and said cationic photoinitiator is present from 0.1-2

parts by weight, all based on 100 parts by weight of said material composition.

15. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 further comprising a non-reactive diluent for reducing a viscosity of said material

composition.

16. (Currently Amended) A material composition as set forth in claim 1 comprising:

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a first component having a monomer portion and at least one cationically

polymerizable functional group;

a crosslinker reactive with said first component and comprising at least three

cationically polymerizable functional groups;

a cationic photoinitiator, and

a non-reactive diluent for reducing a viscosity of said material composition wherein

said non-reactive diluent is selected from the group of PGMEApropylene glycol

monomethyl ether acetate, PGMEpropylene glycol monomethyl ether, 2-heptanone, xylene,

and combinations thereof.

17. (Cancelled)

18. (Currently Amended) A material composition An article as set forth in claim

[[1]]<u>36</u> wherein;

said first component comprises two epoxy functional groups and said monomer

portion of said first component is an organosilicone monomer; and

said crosslinker comprises silicone and four epoxy functional groups.

19. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said composition is applied on a substrate to form a film by spin-coating,

dip-coating, or spray-coating.

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20. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said composition is applied on a substrate as liquid droplets prior to contact

printing.

21. (Currently Amended) Use of the A method comprising the step of imprinting a

material composition comprising:

a first component having a monomer portion and at least one cationically

polymerizable functional group;

a crosslinker reactive with said first component and comprising at least three

cationically polymerizable functional groups; and

a cationic photoinitiator,

of claim 1 inthrough at least one of nanoscale contact printing, nanoimprint lithography

(NIL), microimprint lithography, UV-assisted nanoimprint lithography, Step-and-Flash

Nanoimprint Lithography (S-FIL), and combined-nanoimprint-and-photolithography.

22. (Currently Amended) Use of the material composition of claim 1 in A method as

set forth in claim 21 wherein a tool selected from the group of contact aligners,

nanoimprinters, bonding machines, and presses is used for the step of imprinting.

23. (Currently Amended) Use of the material composition of claim 1A method as

set forth in claim 21 wherein the material is imprinted at temperatures between 0 and 100°C

and/or at pressures less than 10 atmospheres.

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24-34. (Cancelled)

35. (Currently Amended) A cured resist film An article as set forth in claim [[24]]36 wherein said resist film is of the general formula;

36. (Currently Amended) An article comprising:

a substrate layer; and

a resist layer formed on said substrate layer and comprising the reaction product of thea material composition of claim 1comprising:

a first component comprising a monomer portion and at least one cationically polymerizable functional group;

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a crosslinker reactive with said first component and comprising at least three

cationically polymerizable functional groups; and

a cationic photoinitiator; and

an undercoating layer disposed between said substrate layer and said resist layer.

37. (Original) An article as set forth in claim 36 wherein said substrate layer is

formed from silicon or glass.

38. (Cancelled).

39. (Currently Amended) An article as set forth in claim [[38]]36 wherein said

undercoating layer is formed from a polymer.

40. (Original) An article as set forth in claim in claim 39 wherein said polymer

comprises poly(methyl methacrylate).

41-50. (Cancelled)

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